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Sheet 1 of 1

Form PTO-1449 (REV. 1/06)		US Dept. of Commerce PATENT & TRADEMARK OFFICE		ATTY DOCKET NO. 127104			APPLICATION NO. 10/569,207	
INFORMATION DISCLOSURE STATEMENT								
(Use several sheets if necessary)				APPLICANT(S) Takeshi SHIRAI et al.				
				FILING DATE February 23, 2006			GROUP 2872	
U.S. PATENT DOCUMENTS								
Examiner Initials	Cite No.	Document Number	Da	ite	Name			
/AA/	1	6,417,974	07/09/20	02	Schuster			
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/AA/	5	EP 1 646 074 A1	04/12/200	06	ЕРО			
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Examiner Initials	Cite No.	Including name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.						
/AA/	6	M. SWITKES et al., Immersion Liquids for Lithography in the Deep Ultraviolet, Optical Microlithography XVI, 2003, 690-699, Vol. 5040 (2003)						
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Date: November 7, 2008